Experiments and Particle-in-Cell Simulation on Self-Oscillations and Period Doubling in Thermionic Discharges at Low Pressure

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The mechanism of different discharge modes, self-oscillations, and the period-doubling route to chaos is studied by comparing experimental results from a filament cathode discharge with particle-in-cell simulations. The self-oscillation process invokes ion trapping by charge exchange, double layer forrnation, and ion depletion. The exhausting of resources which underlies the period-doubling route is identified with incomplete ion refilling.

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Discharges with filament cathodes at pressures of about $10⁻¹$ Pa are in widespread use in magnetic box devices [1], double plasma arrangements [2], or ion sources [3]. Their inherent hysteresis of the $I(U)$ characteristic [4,5] has attracted much interest from the viewpoints of catastrophe theory [6] and nonlinear dynamics [7]. Under certain discharge conditions thermionic discharges perform low-frequency oscillations [8], which can be driven to chaos either by varying the discharge parameters [9] or by applying external modulation [10]. Routes to chaos via intermittency [11] and period doubling [7,12] were observed. Cheung and Wong [7] have discussed the role of ion dynamics and electron neutral collisions in perioddoubling scenarios. In the present paper we intend to identify the detailed interplay of plasma processes, which lead to period-doubling transition to chaos.

Our investigations are performed in a magnetic box device with filament cathode [12] (Fig. 1). This device has been selected as a typical representative of this class of discharge. The discharge is operated in argon at p $=0.03-0.3$ Pa. The anode voltage can be modulated by additionally applying periodic pulses of a few kHz frequency. The spatiotemporal evolution of plasma parameters and plasma potential is measured with movable Langmuir and emissive probes.

The general behavior of this discharge is compiled in Fig. 2. The $I(U)$ characteristic shows the well-known hysteresis curve. The upper branch represents the "temperature-limited mode" (TLM); the lower branch is the "anode-glow mode" (AGM) in the classical terminology for thermionic discharges [13,14]. In our case the states are similar to the above-mentioned collisional discharges despite the fact that the mean free path for electron and ion collisions with neutrals is comparable to the plasma dimensions. For these low pressure thermionic discharges the AGM is established by producing ions in the anode sheath and trapping them by charge exchange in the potential well of the virtual cathode. The resulting plasma potential distribution [Fig. 2(b)] shows a cathodic plasma, which is close to the cathode potential, and an anode layer, where the plasma potential increases to anode potential. From the discharge current we estimate the electron density to be of the order $n_e \approx 10^{14}$ m⁻³. In the TLM, the plasma potential distribution is homogeneous and close to anode potential [Fig. 2(a)] except for a cathode sheath which is not accessible by emissive probes. The plasma parameters $n_e = 10^{16}$ m⁻³ and $T_e = 2$ eV are obtained from Langmuir probes. Self-oscillations of the discharge current with large amplitudes [Fig. 2(d)] are observed in the AGM close to the right hysteresis point. Their typical frequency lies between 1-2 kHz and depends on the detailed discharge parameters. The plasma potential increases during a current spike [Figs. 2(c),2(d)]. Potential and current spikes have a fast rising edge and a more gradual decay.

Large amplitude oscillations have been studied extensively via computer simulations for thermionic plasma converters and Q machines [8,15,16]. In our simulations

FIG. l. Magnetic box discharge with filament cathode. A pulse generator is used for external modulation. The diagnostic tools are movable Langmuir and emissive probes.

FIG. 2. Experimental results. Center panel: $I(U)$ hysteresis curve. Plasma potential distribution of the (a) temperature-limite mode and (b) anode-glow mode. The potential contours are recorded along the chamber axis. (c),(d) Experimentally obtained selfoscillations of plasma potential and discharge current.

the PIC-MCC code pDPI [17] is used, which has one space dimension but three velocity components, and includes elastic, inelastic, charge exchange, and ionizing collisions. The self-spiking process is studied at a more realistic mass ratio $(m_i/m_e = 10000)$ than reported in [18]. The simulation parameters are chosen very similar to laboratory conditions (i.e., gas pressure $P=0.06$ Pa, discharge voltage $U_d = 20$ V, length $L = 15$ cm, filament temperature $T_f = 2300$ K, collision cross sections for argon). The simulation starts with an empty electrode gap, and ion trapping by charge exchange fills the cathodic plasma. In the absence of ion losses the simulation always shows current spikes $[Fig. 3(a)]$ and an increase of plasma potential. Including ion losses, self-spiking is only observed above a critical discharge voltage. The evolution of electron and ion phase space as well as the potential distribution during a single spike are given in Fig. 3(d). The sequence of events can be described by a filling phase (panels ¹ and 2), during which ions are produced in the anode sheath and are trapped in the cathodic plasma, while the potential distribution is of AGM type. This cathodic plasma gradually expands towards the anode. Once the cathodic plasma becomes ion rich, the plasma potential in the cathodic plasma rises (panel 3). An electron hole [19] forms and transforms into a double layer (panel 4). By the double layer's electric field, electrons as well as ions of the cathodic plasma are accelerated in opposite directions. We always observe electrostatic waves at the plasma frequency which travel towards the anode. Ions streaming into the cathode sheath reduce the negative space charge and further enhance the current (panel 4). The accelerated ions represent an appreciable loss of ions in the cathodic plasma on the high potential side of the double layer which ultimately leads to its destruction. Finally, the current pulse is quenched by the formation of a negative potential dip [Fig. 3(c), panel 5].

FIG. 3. PIC simulation of self-spiking process. (a) Discharge current, (b) plasma potential at $x = 7.5$ cm, and (c) minimum plasma potential. The dashed line marks cathode potential. For (a) to (c), the horizontal axis is the time. (d) From left to right: Plasma potential (scale $\Phi = -22-0$ V), density distribution (dotted lines n_i , straight lines n_e , scale $n_{e,i}$ $=0-2.67\times10^{12}$ cm⁻³), electron phase space (scale $v_e = +2.5$) \times 10⁶ m/s), and ion phase space (scale $v_i = \pm 2.5 \times 10^4$ m/s) for the instants marked in (a). Cathode position is on the left $(x=0 \text{ cm})$ and anode on the right $(x=15 \text{ cm})$.

FIG. 4. Comparison of experimentally obtained currente high pass filtered signal
($f \approx 50$ kHz) accompanie the current spike. frequency burst $(f \approx 50 \text{ kHz})$ accompanies the rising edge of

The cathodic plasma becomes electron rich, and the refilling starts again (panel 6). The repetition time of the current spikes is determined by the time scale for refilling hodic plasma. Hence, the spike strongly dependent on the neutral gas pr ture of the described oscillations strongly resembles the ion instability [20]. In addition, similar dynamic potential structures were obse in-cell (PIC) simulations of positively biased Q machines $[16]$.

Experimental evidence of a low-frequency instability which is associated with the current spikes is given in Fig. 4. The discharge current shows fluctuations with a typical frequency of 50 kHz which start at the rising edge of he current pulse and last for about 400 μ s. We have also tried to detect the high-frequency fluctuations at the plasma frequency. But in contrast to obse a longitudinal magnetic field [18], no ial hf signals were found between 30-1400 MHz, where one would expect electron plasma waves.

In the experiment, there are two ways system from regular to chaotic motion. The first is by increasing the driver amplitude in mode-locked states [21]. In the second case, the dc discharge conditions are chosen on the AGM branch where self-spiking is not yet excited. Short pulses of about 2 kHz repetition frequency, which exceed the hysteresis point transiently, are applied. Consequently, the plasma potential as well as the discharge ollow a period-doubling route to chao (Fig. 5). Figure 6 shows the corresponding bifurcation diagram and 3D embedded phase space $[22]$ of the period doubled and the chaotic star $\frac{1}{221}$ of the period dodored and the endore been demonstrated. In addition, the int dentified to be the number of newly gencrated ions per period.

The shape of the chaotic attractor (Fig. 6) closely

⁷IG. 5. Response of the plasma pot pulse width the syst discharge experiment. By increasing the chaos. (a) Period $p = 1$, (b) $p = 2$, (c) $p = 4$, and (d) chaos.

resembles the logistic mapping [23], which, roughly ing, describes dynamical systems d-doubling scenario because of exhausting resources. To understand period doubling in the present erefore necessar y to answer the ollowing question: Why is a strong cu en ancement, followed by
Sma potential enhancement, followed by
This suppression mechanism is reveale

This suppression mechanism is revealed by observing equency has to be chosen close to twice he natural spiking frequency, which wo slightly increased dc operating voltage. This idea is fur-

FIG. 6. Experimental bifurcation

onstruction {coordinate axis = $[I]$

b) Security and distributed the security of the second security of the second security e effective pulse width $(P=2$ at $U_{\text{OFS}} = 26.7 \text{ V}$, chaos at U_{OFS} =29.6 V). Note the transition to the TLM after sect to vary the encetive pulse when $\frac{(r - 2)}{r}$ at $\frac{0.055 - 2}{0.055}$ chaos at $U_{\text{OFS}} = 29.6 \text{ V}$). Note the transition to the TLM passing a critical control parameter value $U_{\text{OFS}} = 33.5 \text{ V}$.

FIG. 7. PIC simulation of a period-doubled state. (a) External driver voltage, (b) discharge current response, and (c) potential response at $x = 7.5$ cm.

ther corroborated by the fact that the self-spiking state can easily be mode locked $[10,21]$. In addition, for high modulation amplitude within the mode-lock two state, the phase space attractor is nearly identical with Fig. 6. First PIC simulations of the mode-lock two state $[18]$ show that the discharge current forms a strictly alternating series of strong and weak current pulses (Fig. 7). For such a period-two state, the forced self-spiking mechanism occurs during the strong current pulse, whereas during a weak pulse no plasma reorganization occurs. Evidently, the formation of the double layer is subjected to a threshold condition, which may be related to the Buneman-type instabilities [24]. As a consequence, we suggest that the efficient depletion of ions from the cathodic plasma during a spike and the incomplete refilling by trapping charge-exchange ions forms the mechanism that gives the system a noninvertible dynamical return map resembling the logistic mapping. The measured quadratic shape of the return map immediately yields the possibility of generating period 4, 8, etc. and chaotic states.

To summarize, the connections between the mechanism of the AGM, the self-spiking process, and the perioddoubling route have been established by comparing the behavior of a typical thermionic filament discharge with PIC simulations. The period-doubling scenario is intiplasma during a strong current spike. Period doubling is also related to the chaos transition within the mode-lock two state.

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